## WHAT IS CLAIMED IS:

- 1. A method for producing a silica gel, which comprises hydrolyzing a silicon alkoxide and subjecting the resulting hydrogel to a hydrothermal treatment substantially without aging it.
- 5 2. The method for producing a silica gel according to Claim 1, wherein a hydrogel having a breaking stress of at most 6 MPa is subjected to the hydrothermal treatment.
- 3. The method for producing a silica gel according to Claim 1, wherein the hydrothermal treatment is carried out at a temperature of from 50 to 150°C for from
  10 1 to 10 hours.
  - 4. The method for producing a silica gel according to Claim 1, wherein an ammonia water is used for the hydrothermal treatment.
  - 5. The method for producing a silica gel according to Claim 1, wherein an obtained silica gel is a silica gel which has the following characteristics:
- 15 (a) the pore volume is from 0.6 to 1.6 ml/g,
  - (b) the specific surface area is from 300 to 900 m<sup>2</sup>/g,
  - (c) the mode diameter (Dmax) of pores is less than 20 nm,
  - (d) the volume of pores having diameters within  $\pm 20\%$  of Dmax is at least 50% of the total pore volume,
- 20 (e) it is amorphous, and
  - (f) the content of metal impurities is at most 500 ppm.
  - 6. The method for producing a silica gel according to Claim 1, wherein

hydrolysis of said silicon alkoxide is conducted in the absence of a template.

- 7. A silica gel, produced by a process comprising hydrolyzing a silicon alkoxide and subjecting the resulting hydrogel to a hydrothermal treatment substantially without aging it.
- 8. The silica gel according to Claim 7, wherein a hydrogel having a breaking stress of at most 6 MPa is subjected to the hydrothermal treatment.
  - 9. The silica gel according to Claim 7, wherein the hydrothermal treatment is carried out at a temperature of from 50 to 150°C for from 1 to 10 hours.
- 10. The silica gel according to Claim 7, wherein an ammonia water is used forthe hydrothermal treatment.
  - 11. The silica gel according to Claim 7, wherein an obtained silica gel is a silica gel which has the following characteristics:
    - (a) the pore volume is from 0.6 to 1.6 ml/g,
    - (b) the specific surface area is from 300 to 900 m<sup>2</sup>/g,
- 15 (c) the mode diameter (Dmax) of pores is less than 20 nm,
  - (d) the volume of pores having diameters within  $\pm 20\%$  of Dmax is at least 50% of the total pore volume,
    - (e) it is amorphous, and
    - (f) the content of metal impurities is at most 500 ppm.
- 20 12. The silica gel according to Claim 11, wherein the pore volume is from 0.8 to 1.6 ml/g.
  - 13. The silica gel according to Claim 11, wherein the specific surface area is

from 400 to 900  $m^2/g$ .

- 14. The silica gel according to Claim 11, wherein the mode diameter (Dmax) is at least 2 nm.
- 15. The silica gel according to Claim 11, wherein the volume of pores having diameters within  $\pm 20\%$  of Dmax is at least 60% of the total pore volume.
  - 16. The silica gel according to Claim 11, wherein the content of metal impurities is at most 10 ppm.
  - 17. The silica gel according to Claim 11, wherein the content of metal impurities is at most 1 ppm.
- 18. The silica gel according to Claim 11, wherein the differential pore volume at the mode diameter (Dmax) is from 5.0 to 12.0 ml/g.
  - 19. The silica gel according to Claim 11, wherein the value of Q4/Q3 in solid state Si-NMR is at least 1.3.
- 20. The silica gel according to Claim 7, wherein hydrolysis of said siliconalkoxide is conducted in the absence of a template.
  - 21. The silica gel according to Claim 11, wherein hydrolysis of said silicon alkoxide is conducted in the absence of a template.
    - 22. A silica gel which has the following characteristics:
    - (a) the pore volume is from 0.6 to 1.6 ml/g,
- 20 (b) the specific surface area is from 300 to 900 m<sup>2</sup>/g,
  - (c) the mode diameter (Dmax) of pores is less than 20 nm,
  - (d) the volume of pores having diameters within  $\pm 20\%$  of Dmax is at least

50% of the total pore volume,

- (e) it is amorphous, and
- (f) the content of metal impurities is at most 500 ppm.
- 23. The silica gel according to Claim 22, wherein the pore volume is from 0.8 to 1.6 ml/g.
  - 24. The silica gel according to Claim 22, wherein the specific surface area is from 400 to 900 m<sup>2</sup>/g.
  - 25. The silica gel according to Claim 22, wherein the mode diameter (Dmax) is at least 2 nm.
- 10 26. The silica gel according to Claim 22, wherein the volume of pores having diameters within  $\pm 20\%$  of Dmax is at least 60% of the total pore volume.
  - 27. The silica gel according to Claim 22, wherein the content of metal impurities is at most 10 ppm.
- 28. The silica gel according to Claim 22, wherein the content of metal impurities is at most 1 ppm.
  - 29. The silica gel according to Claim 22, wherein the differential pore volume at the mode diameter (Dmax) is from 5.0 to 12.0 ml/g.
  - 30. The silica gel according to Claim 22, wherein the value of Q4/Q3 in solid state Si-NMR is at least 1.3.
- 20 31. The silica gel according to Claim 22, which is produced by means of a step of hydrolyzing a silicon alkoxide.